

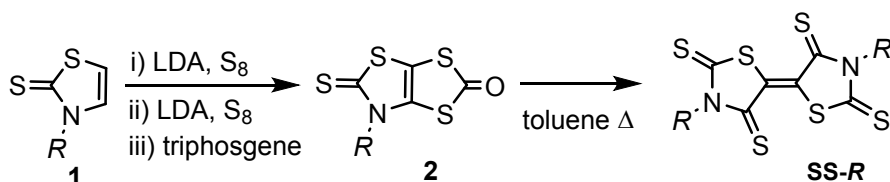
Supporting Information

Temperature-dependent characteristics of n-channel transistors based on 5,5'-bithiazolidinylidene-2,4,2',4'-tetrathiones

Suho Ryo,^a Dongho Yoo,^a Kodai Iijima,^a Ryonosuke Sato,^a Yann Le Gal,^b Dominique Lorcy,^b and Takehiko Mori^{*a}

Synthesis

All commercial chemicals and solvents were used without further purification. Amylamine (A0445), and hexylamine (H0134) were obtained from TCI. Carbon disulfide (038-01246) was obtained from Wako. The data of Nuclear Magnetic Resonance spectrum (NMR) and Mass spectrum (MS) were obtained with a JEOL JNM-AL300 spectrometer and a JEOL JMS-Q1050GC mass spectrometer, respectively.



3,3'-Dimethyl-5,5'-bithiazolidinylidene-2,4,2',4'-tetrathione (SS-R).

Under nitrogen atmosphere, to a -10 °C cooled solution of *N*-alkyl-1,3-thiazole-2-thione **1** (7.6 mmol)⁸ in dry THF (50 ml) was added a solution of lithium diisopropylamide (LDA) freshly prepared from *n*-butyl lithium (*n*-BuLi) (11.5 mmol, 7.2 mL) and diisopropylamine (11.5 mmol, 1.6 mL) in 30 mL dry THF. After stirring for 30 min at -10 °C, S₈ (11.5 mmol, 366 mg) was added and the solution was stirred for additional 30 min. To the medium, a solution of LDA freshly prepared from *n*-BuLi (15.3 mmol, 9.6 mL) and diisopropylamine (15.3 mmol, 2.2 mL) in 30 mL dry

THF was added. The reaction mixture was stirred at $-10\text{ }^{\circ}\text{C}$ for 3 h and sulfur S_8 (12.6 mmol, 403 mg) was added. After 30 min, triphosgene (11.4 mmol, 3.38 g) was added and stirred for 30 min at $-10\text{ }^{\circ}\text{C}$ and further stirred at room temperature overnight. The solution was evaporated *in vacuo* and extracted with dichloromethane and washed with water. The organic layer was dried over MgSO_4 and evaporated *in vacuo*. The crude product was purified by column chromatography using dichloromethane as eluent to afford **2** as a brown solid.

A solution of **2** in 50 mL toluene was refluxed overnight. 90% of the solution was evaporated *in vacuo* and the precipitate was filtered and washed with ethanol and dried *in vacuo* to afford **SS-R** as a black solid. Crystals of sufficient quality for X-ray diffraction were obtained by slow evaporation of CH_2Cl_2 .

SS-Pen: Yield: 45% (740 mg). ^1H NMR (300MHz, CDCl_3) δ 0.98 (t, 3H, CH_3 , $J = 7.4$ Hz), 1.74 (m, 2H, CH_2), 1.38 (m, 2H, CH_2), 3.78 (m, 2H, CH_2); HRMS (ASAP) calcd for $\text{C}_{16}\text{H}_{22}\text{N}_2\text{S}_6$ $[\text{M} + \text{H}]^+$: 434.776. Found: 434.8932; Anal. calcd for $\text{C}_{16}\text{H}_{22}\text{N}_2\text{S}_6$: C, 44.20; H, 5.10; N, 6.44. Found: C, 43.96 ; H, 4.87; N, 6.18.

SS-Hex: Yield 48% (840 mg). ^1H NMR (300MHz, CDCl_3) δ 0.98 (t, 3H, CH_3 , $J = 7.4$ Hz), 1.78 (m, 2H, CH_2), 1.35 (m, 2H, CH_2), 3.88 (m, 2H, CH_2); HRMS (ESI) calcd for $\text{C}_{12}\text{H}_{14}\text{N}_2\text{S}_6$ $[\text{M} + \text{H}]^+$: 462.828. Found: 462.9562; Anal. calcd for $\text{C}_{18}\text{H}_{26}\text{N}_2\text{S}_6$: C, 46.72; H, 5.66; N, 6.05. Found: C, 46.62; H, 5.46; N, 6.14.

Cyclic Voltammetry (CV) and ultraviolet-visible spectroscopy (UV-Vis)

Redox potentials were measured by cyclic voltammetry. Dry dichloromethane was used as a solvent, $\text{Bu}_4\text{N}\cdot\text{PF}_6$ as an electrolyte and ALS-701E as a measuring instrument. An Ag/AgNO_3 electrode was used for the reference electrode, and glassy carbon and platinum electrodes were used for the working electrode and the auxiliary electrode, respectively.

Ultraviolet-visible absorption spectra were measured at room temperature using a quartz cuvette having a 1 cm path using a UV-1800 ultraviolet-visible spectrophotometer (Shimadzu). Dichloromethane was used as a solvent. With increasing the alkyl chain length, the splitting of the 500-600 nm peak became less important probably because it is related to the intermolecular interaction. The optical band gap (HOMO-LUMO gap) was calculated from the edge of the visible absorption band.

Crystal Structures

The X-ray oscillation photographs for **SS-Pen** were taken using a RIGAKU R-AXIS RAPID II imaging plate with $\text{CuK}\alpha$ radiation from a rotation anode source with a confocal multilayer X-ray mirror (RIGAKU VM-Spider, $\lambda = 1.54187 \text{ \AA}$). Diffraction data for **SS-Hex** were collected on a Rigaku AFC-7R four-circle diffractometer using $\text{MoK}\alpha$ radiation from a rotation anode source ($\lambda = 0.71069 \text{ \AA}$). The structures were solved by the direct method (SHELXT) and refined by the full-matrix least-squares method by applying anisotropic temperature factors for all non-hydrogen atoms using the SHELXL programs.^{S1,S2} The hydrogen atoms were placed at geometrically calculated positions. Transfer integrals were estimated from the overlap of the molecular orbitals.²⁶

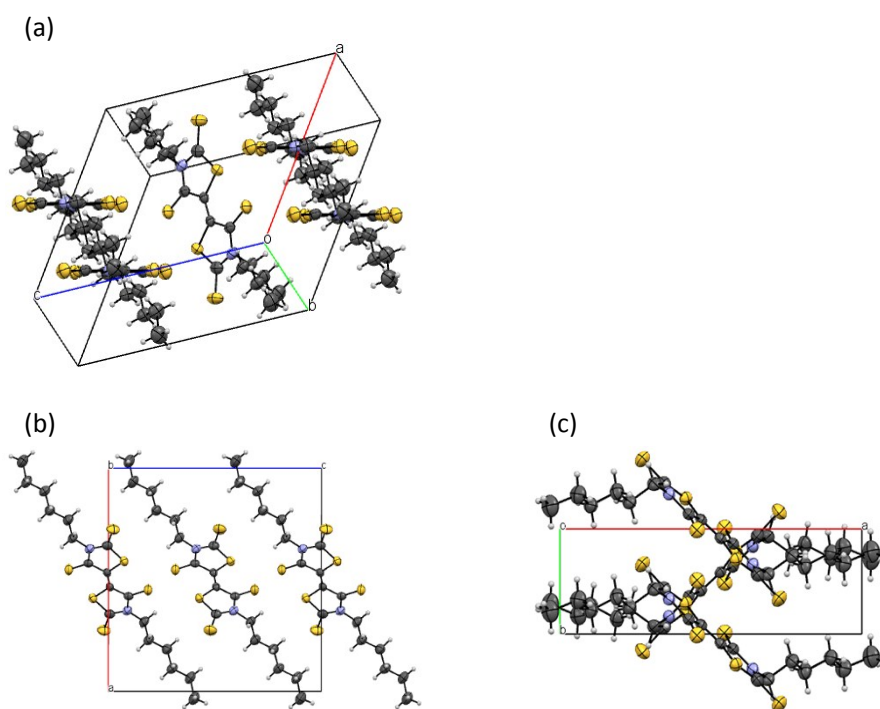


Figure S1. (a) Crystal structure of **SS-Hex** viewed along the molecular long axis. (b) Crystal structure of **SS-Hex** viewed along the *b* axis, and (b) along the *c* axis.

Thin film properties

X-ray diffraction analyses of thin films (50 nm) on TTC (20 nm) were performed by X'pert-Pro-MRD using the θ - 2θ technique with Cu- $K\alpha$ radiation for $2^\circ \leq 2\theta \leq 20^\circ$. AFM images of thin films (50 nm) on TTC (20 nm) were taken by a SII scanning probe microscope system SPI3800N and SPA-300 by using a Si₃N₄ cantilever.

Transistor characteristics

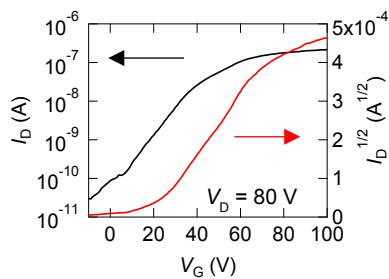


Figure S2. Transfer characteristics of an **SS-Hex** single-crystal transistor.

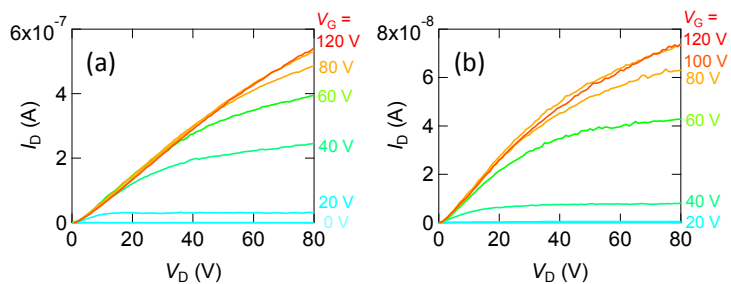


Figure S3. Output characteristics of single-crystal transistors measured at room temperature for (a) **SS-Pen** (*I/b*), and (b) **SS-Hex** (*I/b*).

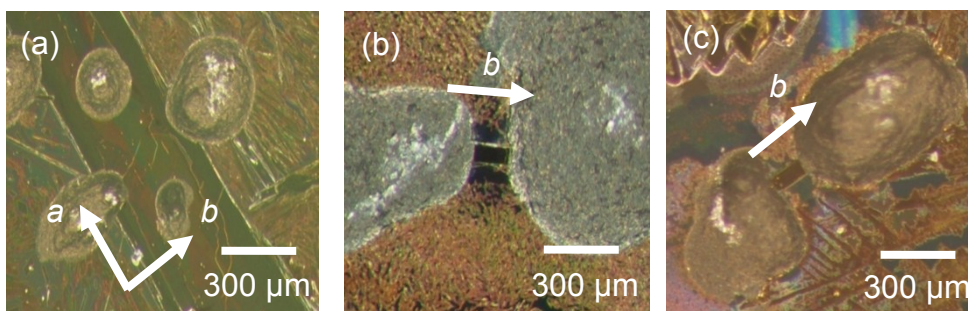


Figure S4. Single-crystal transistors of (a) **SS-Pr**, (b) **SS-Pen**, and (c) **SS-Hex**.

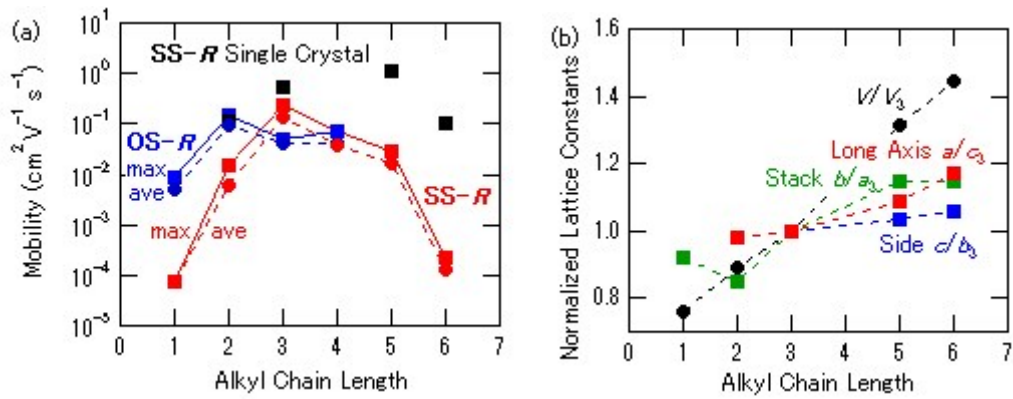


Figure S5. (a) Summary of mobility. (b) Lattice constants normalized by $a_3 \sim c_3$ and V_3 of SS-Pr.

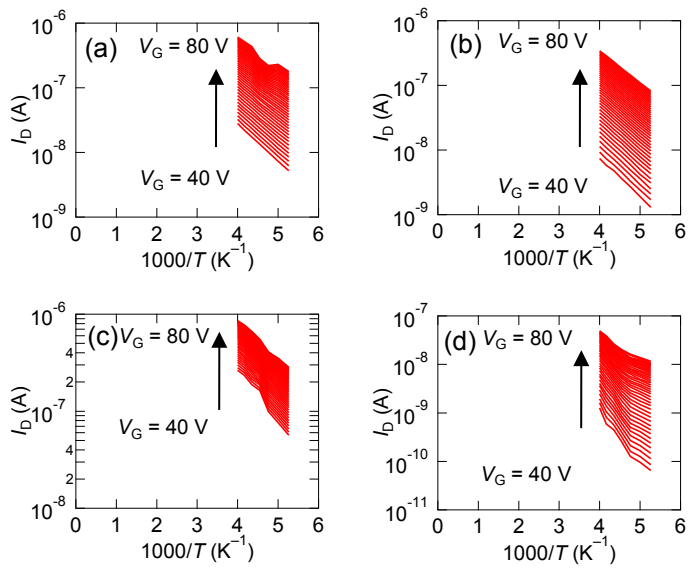


Figure S6. Arrhenius plots of I_D for transistors of (a) SS-Pr ($//a$), (b) SS-Pr ($//b$), (c) SS-Pen ($//b$), and (d) SS-Hex ($//b$).

References

- S1 Sheldrick, G. M. SHELXT – Integrated Space-Group and Crystal Structure Determination. *Acta Crystallogr. A*. 2015, **71**, 3.
- S2 Sheldrick, G. M. Crystal Structure Refinement with SHELXL. *Acta Crystallogr. C*. 2015, **71**, 3.